

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 10813543
Filing Date March 3, 2004
Confirmation No. 8087
Inventor Gealy, F. Daniel
Assignee Micron Technology, Inc.
Group Art Unit 1792
Examiner Chen, Keath T.
Attorney's Docket No. MI22-3685
Title:Method for Reducing Physisorption During Atomic Layer Deposition

RESPONSE TO APRIL 1, 2008 OFFICE ACTION

To: Mail Stop Amendment
Commissioner for Patents
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